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10/731,356	12/09/2003	Bruno Dc Man	Bruno De Man 133642-1/YOD 438 GERD:0068	
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	ECTRIC COMPANY	CHU, RANDOLPH I		
C/O FLETCHE	-	CHU, KANDOLPH I		
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Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

		Application No.	Applicant(s)			
		10/731,356	MAN, BRUNO DE			
	Office Action Summary	Examiner	Art Unit			
		Randolph Chu	2624			
	The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply					
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).						
Status	÷		·			
1)⊠	Responsive to communication(s) filed on 17 Au	<u>igust 2007</u> .	·			
2a)⊠	This action is FINAL . 2b) ☐ This action is non-final.					
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.					
Dispositi	Disposition of Claims					
4)⊠	Claim(s) 1-22 is/are pending in the application.					
-	4a) Of the above claim(s) is/are withdrawn from consideration.					
	Claim(s) is/are allowed.		•			
•	6)⊠ Claim(s) <u>1-22</u> is/are rejected.					
7)	Claim(s) is/are objected to.					
8)	Claim(s) are subject to restriction and/or	r election requirement.				
Application Papers						
9)[]	The specification is objected to by the Examine	r.				
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
,,	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).					
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11)[The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form PTO-152.			
Priority (under 35 U.S.C. § 119					
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a) ☐ All b) ☐ Some * c) ☐ None of:						
1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents have been received in Application No						
3. Copies of the certified copies of the priority documents have been received in this National Stage						
application from the International Bureau (PCT Rule 17.2(a)).						
* See the attached detailed Office action for a list of the certified copies not received.						
	•					
Attachmen	ot(s)					
	ce of References Cited (PTO-892)	4) Interview Summary				
	ce of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO/SB/08)	Paper No(s)/Mail Da 5) Notice of Informal P				
	er No(s)/Mail Date	6) Other:	• •			

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DETAILED ACTION

Response to Amendment

2. In response to applicant's amendment received on August 17, 2007, all requested changes to the claims have been entered.

Response to Argument

3. Applicant's arguments filed on August 17, 2007 have been fully considered but they are not persuasive.

Applicant's argue on page 7 of the response that the disclosure of De Man does not disclose adjusting or otherwise altering the <u>measured data</u>.

The examiner disagrees. Abstract of De Man Stated "Based on simulations and measurements, the most important causes of metal artifacts were determined".

Also Applicant's argue on pages 7-13 of the response that the disclosure of De Man does not disclose the measured sinogram elements are iteratively adjusted at least in the trace of the high density object in the measured sinogram data based upon an optimization criterion in the image domain to generate corrected sinogram.

The examiner disagrees. The Prior art of De Man the measured sinogram (1) elements are iteratively adjusted (1) at least in the trace of the high density object (p_i)

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the measured sinogram data based upon an optimization criterion (3-5) in the image domain to generate corrected sinogram (5) (page 108).

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

2. Claims 1, 2, 13, 14, 18-22 is/are rejected under 35 U.S.C. 102(b) as being anticipated by Man ("Iterative Reconstruction for Reduction of Metal Artifacts in Computed Tomography").

With respect to claim 1, Man teaches,

receiving measured sinogram data from the computed tomography system, the sinogram data representative of a plurality of measured sinogram elements (pages 13-17);

reconstructing the measured sinogram data to generate initial reconstructed image data (pages 17-23);

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identifying a trace of the high density object in the measured sinogram data (pages 82-84);

identifying a region of interest in the initial reconstructed image data (pages 82-84);

identifying an optimization criterion based upon the region of interest in an image domain (pages 59-60);

iteratively adjusting the measured sinogram (1) elements are iteratively adjusted (1) at least in the trace of the high density object (p_i) the measured sinogram data based upon an optimization criterion (3-5) in the image domain to generate corrected sinogram (5) (Page 108); and

reconstructing the corrected sinogram data to generate improved reconstructed image data (page 98).

With respect to claim 2, Man teaches, the initial reconstructed image data is generated using a filtered back projection technique (pages 17-21).

With respect to claim 10, Man teaches, the optimization criterion comprises determining an optimal attenuation value associated with the region of interest (Fig. 3.8)

With respect to claim 11, Man teaches, wherein the optimization criterion comprises determining an optimal uniformity value associated with the region of interest

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(page 105, 5th paragraph)

With respect to claim 12, Man teaches, the optimization criterion comprises minimizing angular variations associated with the region of interest based on the relative position of the region of interest with respect to the high density object (page 135, 3rd paragraph)

With respect to claim 13, Man teaches, reconstructing the corrected sinogram data to generate improved reconstructed image data comprises using a filtered back projection technique (pages 17-21).

With respect to claim 18, Man teaches,

an x-ray source configured to project an x-ray beam from a plurality of positions through the subject of interest (page 9);

a detector configured to produce a plurality of electrical signals corresponding to the x-ray beam (page 13); and

a processor configured to process the plurality of electrical signals to generate measured sinogram data, the sinogram data representative of a plurality of measured sinogram elements, wherein the processor is further configured to reconstruct the measured sinogram data to generate initial reconstructed image data (pages 13-23);

identify a trace of the high density object in the measured sinogram data (pages 82-84);

identify a region of interest in the initial reconstructed image data (pages 82-84); identify an optimization criterion based upon the region of interest in an image domain (pages 59-60);

iteratively adjust iteratively adjusting the measured sinogram (1) elements are iteratively adjusted (1) at least in the trace of the high density object (p_i) the measured sinogram data based upon an optimization criterion (3-5) in the image domain to generate corrected sinogram (5) (Page 108); and

reconstruct the corrected sinogram data to generate improved reconstructed image data (page 98).

With respect to claim 14, please refer to rejection for claim 1.

With respect to claim 19, please refer to rejection for claim 1.

With respect to claim 20, please refer to rejection for claim 1.

With respect to claim 21, please refer to rejection for claim 1.

With respect to claim 22, please refer to rejection for claim 1.

Claim Rejections - 35 USC § 103

3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

⁽a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the

invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

4. Claim 7 is rejected under 35 USC 103(a) as being unpatentable over Man ("Iterative Reconstruction for Reduction of Metal Artifacts in Computed Tomography") in view of Hsieh (US Patent 6,385,278).

Man teaches all the limitations of claim 1 as applied above from which claim 7 respectively depend.

Man does not teach expressly that identifying a region of interest is based on an attenuation value associated with the region of interest.

Hsieh teaches identifying a region of interest is based on an attenuation value associated with the region of interest (abstract).

At the time of the invention it would have been obvious to a person of ordinary skill in the art to identify a region of interest is based on an attenuation value associated with the region of interest in the method of Man.

The suggestion/motivation for doing so would have been that region of interest and non – region of interest should have significant difference in attenuation, so region of interest can be easily identified using attenuation.

Therefore, it would have been obvious to combine Hsieh with Man to obtain the invention as specified in claim 7.

5. Claim 8 is rejected under 35 USC 103(a) as being unpatentable over Man ("Iterative Reconstruction for Reduction of Metal Artifacts in Computed Tomography") in view of Luo (US 2004/0001569).

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Man teaches all the limitations of claim 1 as applied above from which claim 8 respectively depend.

Man does not teach expressly that identifying a region of interest is based on a uniformity value associated with the region of interest.

Luo teaches identifying a region of interest is based on a uniformity value associated with the region of interest (para [0080]).

At the time of the invention it would have been obvious to a person of ordinary skill in the art to identify a region of interest is based on a uniformity value associated with the region of interest in the method of Man.

The suggestion/motivation for doing so would have been that region of interest and non – region of interest should have significant difference in uniformity, so region of interest can be easily identified using uniformity.

Therefore, it would have been obvious to combine Luo with Man to obtain the invention as specified in claim 8.

6. Claim 9 is rejected under 35 USC 103(a) as being unpatentable over Man ("Iterative Reconstruction for Reduction of Metal Artifacts in Computed Tomography") in view of Karimi et al. (US Patent 6,813,374).

Man teaches all the limitations of claim 1 as applied above from which claim 9 respectively depend.

Man does not teach expressly that identifying a region of interest is based on the relative position of the region of interest with respect to the high density object.

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Karimi et al. teaches identifying a region of interest is based on the relative position of the region of interest (col. 11 lines 39-44).

At the time of the invention it would have been obvious to a person of ordinary skill in the art to identifying a region of interest is based on the relative position of the region of interest in the method of Man.

The suggestion/motivation for doing so would have been that region of interest is selected based on relative position so that calculation/manipulation of data is simplified.

Therefore, it would have been obvious to combine Karimi et al. with Man to obtain the invention as specified in claim 9.

Allowable Subject Matter

Claims 3-6 and 15-17 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

The following is an examiner's statement of reasons for allowance: claims 3 and 15-17 are allowable over the prior art of record because non of the prior art of record teaches the combined claimed elements as set forth in the claims 3 and 15-17.

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None of the prior art of record teaches or fairly suggests that image processing method for that reducing artifact by computed topography system with assigning a reliability measure to each sonogram element where in iteratively adjusting the measured sinogram data is based upon the reliability measure or measured sinogram data relative to its position within the trace of the segmented high density object or based on a pre defined threshold value or based on an attenuation value of each sinogram element and together with combination of other claimed elements as set forth in the independent claims 3 and 15-17. Therefore, the claims 3 and 15-17 are over the prior art of records.

Conclusion

7. THIS ACTION IS MADE FINAL. 'Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of

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the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Randolph Chu whose telephone number is 571-270-1145. The examiner can normally be reached on Monday to Thursday from 7:30 am - 5 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Bella can be reached on 571-272-7778. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

RIC/

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